PATENT Reply under 37 C.F.R. § 1.116 Expedited Procedure Technology Center 1762 Attorney Docket No. 037768-0173

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named Inventor:	Attorney Docket No. 037768-0173	
Γapesh YADAV	Group Art Unit: 1762	
Application No.: 10/698,564	Examiner: Elena TSOY	
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Title: High volume manufacturing of nanoparticles and nano-dispersed particles at low cost

MS AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## I. Second Amendment After Final Rejection

This paper responds under 37 C.F.R. § 1.116 to the outstanding final Office action dated 06-09-2008. It is timely as it is filed within the shortened statutory period for reply ending 09-09-2008.

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